

PA-IDC

QUERY CONTROL FORM		RTIS USE ONLY	
Application No. <u>09/325,026</u>	Prepared by <u>DM</u>	Tracking Number <u>05874574</u>	
Examiner-GAU <u>Alejandro-Mulero</u>	Date <u>2/7/04</u>	Week Date <u>12/15/2003</u>	
1763 No. of queries <u>1</u>		IFW	

JACKET			
a. Serial No.	f. Foreign Priority	k. Print Claim(s)	p. PTO-1449
b. Applicant(s)	g. Disclaimer	l. Print Fig.	q. PTOL-85b
c. Continuing Data	h. Microfiche Appendix	m. Searched Column	r. Abstract
d. PCT	i. Title	n. PTO-270/328	s. Sheets/Figs
e. Domestic Priority	j. Claims Allowed	o. PTO-892	t. Other

SPECIFICATION	MESSAGE
a. <u>Page Missing</u>	<u>Original page 8 is missing in the text. Please provide.</u>
b. Text Continuity	
c. Holes through Data	
d. Other Missing Text	
e. Illegible Text	
f. Duplicate Text	
g. Brief Description	
h. Sequence Listing	
i. Appendix	
j. Amendments	
k. Other	
CLAIMS	
a. Claim(s) Missing	
b. Improper Dependency	
c. Duplicate Numbers	
d. Incorrect Numbering	
e. Index Disagrees	
f. Punctuation	
g. Amendments	
h. Bracketing	
i. Missing Text	
j. Duplicate Text	
k. Other	
	<u>Thank you,</u>
	initials <u>DM</u>
	RESPONSE
	<u>Corrected</u>
	initials

a chamber body;
a substrate support member disposed within the chamber body;
a retaining ring coupled to the chamber body, wherein the retaining ring has a feedthrough hole formed therein;
a chamber lid coupled to the retaining ring, wherein the chamber lid forms a fluid inlet, a fluid outlet, and a temperature control channel, and wherein the temperature control channel is fluidly connected to the fluid inlet and fluid outlet; and
a feedthrough disposed in the feedthrough hole fluidly connected to the temperature control channel

121. (New) A processing chamber comprising:

a chamber body;
a substrate support member disposed within the chamber body;
a retaining ring coupled to the chamber body, wherein the retaining ring has a feedthrough hole formed therein;
a chamber lid coupled to the retaining ring, wherein the chamber lid forms a fluid inlet, a fluid outlet, and a temperature control channel, and wherein the temperature control channel is fluidly connected to the fluid inlet and fluid outlet; and
a feedthrough disposed in a feedthrough hole, wherein the feedthrough is fluidly connected to the temperature control channel, and wherein the feedthrough attaches the chamber lid to the retaining ring.

122. (New) A processing chamber comprising:

a chamber body;
a substrate support member disposed within the chamber body;
a retaining ring coupled to the chamber body, wherein the retaining ring has a feedthrough hole formed therein;
a chamber lid for coupling energy from an energy source into an interior portion of the chamber body, wherein the chamber lid forms a fluid inlet, a fluid outlet, and a temperature control channel, and wherein the temperature control channel is fluidly connected to the fluid inlet and fluid outlet; and